PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Hiromi SAITOH

Group Art Unit: 2871

Application No.: 10/608,475

Examiner:

M. T. T. Ton

Filed: June 30, 2003

Docket No.: 104455.01

For:

ELECTRO-OPTICAL PANEL, ELECTRO-OPTICAL PANEL MODULE, AND

PROJECTION DISPLAY DEVICE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- M 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- \boxtimes English-language Abstracts of the non-English language references are attached hereto. See References 1-3 and 5-11.
- M A computer-generated English translation of the following Japanese Patent Publication has been obtained from the website of the Japanese Patent Office ([http://www.jpo.go.jp]), and is attached, but has not been reviewed for accuracy. See References 1, 4, 5, 6, 7, 8, 10 and 11.
- Ø The references are cited by or submitted to the Office in parent application No. 09/455,447, filed December 6, 1999, which is relied upon for an earlier filing date under 35 U.S.C. §120. Thus, copies of these references are not attached. 37 CFR §1.98(d).

Respectfully submitted.

James A_Oliff

Registration No. 27,075

Gerhard W. Thielman Registration No. 43,186

JAO:GWT/gwt

Date: July 28, 2003

OLIFF & BERRIDGE, PLC P.O. Box 19928 Alexandria, Virginia 22320 Telephone: (703) 836-6400

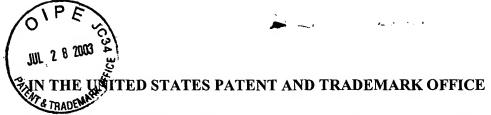
DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our

Deposit Account No. 15-0461

Sheet 1 of 1

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Form PTO-1449 (REV. 8-83)	VEN.	US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY D 104455.0	Y DOCKET NO. APPLICATION NO. 10/608,475			NO.	
INFO	RMAT	ON DISCLOSURE STATEMENT		i					
	(Use	several sheets if necessary)		APPLICANT Hiromi SAITOH					
				FILING June 30,		GR0 287	OUP 1		
		U.S.	PAT	ENT DOC	JMENTS				
EXAMINER INITIAL		DOCUMENT NUMBER		DATE				SUB CLASS	
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	·	FOREIG	GN PA	ATENT DO	CUMENTS				
		DOCUMENT NUMBER		DATE	COUN	ΓRY	CLASS	SUB CLASS	
_	1	JP 11-149254A w/Abstract & Translation		1999	Japan				
	2	JP 63-264720A w/Abstract	11/	1998	Japan				
	3	JP 09-113906A w/Abstract			Japan				
	4	JP 02-095379U w/Translation	07/	1990	Japan				
	5	JP 05-034655A w/Abstract & Translation	02/1	1993	Japan				
	6	JP 10-123964A w/Abstract & Partial Translation	05/1	1998	Japan				
	7	JP 11-084350A w/Abstract & Translation	03/1	1999	Japan				
	8	JP 06-258637A w/Abstract & Translation	09/1	1994	Japan				
	9	JP 01-302386A w/Abstract	12/1	1989	Japan				
	10	JP 11-052325A w/Abstract & Translation	02/1	1999	Japan				
	11	JP 10-232629A w/Abstract & Translation	09/1	1998	Japan				
	12	JP 14-387949A	11/2	2002	Japan				
		OTHER DOCUMENTS (Inc	ludin	g Author,	Title, Date, Pertinent Pag	ges, etc.)			
									
EXAMINER	L	<u> </u>				DATE CONSID	DERED		
		citation considered, whether or not ci					hrough citation	on if not in	

Date: July 28, 2003



In re the Application of: FUKUDA, Tetsuo, et al.

Group Art Unit: Not yet assigned

Serial No.: 10/607,013

Examiner: Not yet assigned

Filed: June 27, 2003

*P3374-0698-030766

For:

SEMICONDUCTOR SUBSTRATE AND METHOD FOR

FABRICATING THE SAME

<u>PURSUANT TO 37 CFR 1.97(b)</u>

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

July 28, 2003

Sir:

The attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached Form PTO-1449. One copy of each of these documents is attached.

No fee or certification is required in connection with this Information Disclosure Statement, since it is being submitted prior to the issuance of a first official action on the merits or expiration of the three month period following the filing date or the entry of the national stage of the above-captioned application.

The above information is presented so that the Patent and Trademark Office can, in the first instance, determine any materiality thereof to the claimed invention. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the documents cited in the attached Form PTO-1449 be made of record therein and appear on the first page of any patent to issue therefrom.

The Commissioner is authorized to charge our Deposit Account No. 01-2340 for any fee which is deemed by the Patent and Trademark Office to be required to effect consideration of this

statement.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

Donald W. Hanson Attorney for Applicants Reg. No. 27,133

DWH/nrp/plb Atty. Docket No. **030766** Suite 1000 1725 K Street, N.W. Washington, D.C. 20006 (202) 659-2930

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PATENT TRADEMARK OFFICE

Enclosures: PTO-1449 (3) and references (23)

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INFORMATION DISCLOSURE CITATION PTO-1449

Atty. Docket No. 030766 Serial No. 10/607,013

Applicant(s): FUKUDA, Tetsuo, et al.

Filing Date: June 27, 2003 Group Art Unit:

U.S. PATENT DOCUMENTS

Examiner Initial		Document No.	Name	Date	Class	Subclass	Filing Date (If appropriate)
	AA				11111		
	AB						

FOREIGN PATENT DOCUMENTS

	Document No.	Date	Country	Translation (Yes or No)
 AC AD	Hei 09-246505 (A)	9-1997	Japan	

OTHER DOCUMENTS

Examiner		Date Considered
	AL	Y. Ishikawa et al., Appl. Phys. Lett., <u>75</u> , p.983 (1999).
	AK	A. R. Powell et al., Appl. Phys. Lett., 64, p.1856, (1994).
	AJ	E. A. Fitzgerald et al., Appl. Phys. Lett., <u>59</u> , p.811, (1991).
	AI	K.K. Linder et al., Appl. Phys. Lett., <u>70</u> , p.3224, (1997).
	AH	D.K. Nayak et al., Appl. Phys. Lett., 70, p.2853, (1993).
	AG	G. Abstreiter et al., Phys. Rev. lett., <u>54</u> , p.2441, (1985).
	AF	Y.Yamaguchi et al., IEEE Trans. Electron Devices, <u>40</u> , p.179, (1993).
	AE	T. Tsuchiya, Prospect of SOI devices, OYO BUTURI, Vol. 66, No. 11, pp.1191-1198, (1997)

INFORMATION
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CITATION
PTO-1449

Filing Date: June 27, 2003

Group Art Unit:

U.S. PATENT DOCUMENTS

Examiner Initial	Document No.	Name	Date	Class	Subclass	Filing Date (If appropriate)

FOREIGN PATENT DOCUMENTS

Document No.	Date	Country	Translation (Yes or No)

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Examiner		Date Considered
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	AS	G. Ottaviani et al., Phys. Rev. <u>B12</u> , p.3318 (1975).
	AR	T. Ruf et al., Solid State Commun., <u>115</u> , p.243, (2000).
	AQ	W.S. Capinski et al., Appl. Phys. Lett. <u>71</u> , p.2109, (1997).
	AP	M. A. Palmer et al., Phy. Rev. B, <u>56</u> , p. 9431, (1997).
-	AO	S. J. Burden, Semiconductor Fabtech, Mar., 2001, 13th Ed., p.297.
	AN	T. Mizuno et al., Tech. Dig. Int. Electron Devices Meet., Washington, (1999), p. 934.
	AM	T. Mizuno et al., IEEE Electron Devices Lett., EDL-21, p.230, (2000).



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INFORMATION DISCLOSURE CITATION			Atty. Docket No. 030766			Serial No	Serial No. 10/607,013		
			Applica	nt(s): FU	KUDA, Tetsu	o, et al.	t al.		
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				U.S. PATE	NT DOCUMI	ENTS			
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			F	OREIGN PA	ATENT DOCU	JMENTS			
		Docu	ıment No.		Date	Country		Translation (Yes or No)	
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	AU T. Sato et al., Phys. Rev. B,4, p.1950, (1971).								
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AU T. Sato et al., Phys. Rev. B,4, p.1950, (1971). AV S. Nakashima, et al., J. Electrochem. Soc. 143, p.244, (1996). AW S. Nakashima et al., Electron, Lett. 26, p.1647, (1990). AX Jaccodine et al, J. Appl. Phys. 37, p.2429, (1966). AY G. Lucovsky et al., The Physics and Chemistry of SiO₂ and the SiO₂ Interface, edited by C.R. Helms et al., Plenum Press, NY, (1988), p.139. AZ H.J. Herzog, et al., J. Electrochem. Soc., 131, p.2969, (1984).